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REPLY UNDER 37 CFR 1.116
EXPEDITED PROCEDURE
TECHNOLOGY CENTER 2800

Docket No.: 015675.P314CX

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Eric Frayssinet

Application No.: 10/695,724

Filed: October 28, 2003

For: **PROCESS FOR PRODUCING AN
EPITAXIAL LAYER OF GALLIUM
NITRIDE**

Art Group: 2823

Examiner: Hsien Ming Lee

**PETITION FOR EXTENSION OF TIME AND
AMENDMENT AND RESPONSE TO FINAL OFFICE ACTION**

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

05/25/2006 TBESHAH1 00000002 10695724

In response to the Final Office Action dated January 18, 2006, Applicant submits the following remarks and amendments to the application: